

comprises:

a discharge array;

an insulator array attached to said discharge array; and

a collection capture array attached to said insulator.

3. (Original) The apparatus of claim 1 wherein said mask has an active area.
4. (Original) The apparatus of claim 3 wherein said pellicle spacer does not obstruct exposure radiation incident on said active area.
5. (Original) The apparatus of claim 2 wherein said discharge array comprises multiple wires that are connected.
6. (Original) The apparatus of claim 5 wherein said multiple wires are laid out as a rectilinear grid.
7. (Original) The apparatus of claim 2 wherein said collection capture array comprises multiple wires that are connected.
8. (Original) The apparatus of claim 7 wherein said multiple wires are laid out as a rectilinear grid.

9. (Original) The apparatus of claim 2 wherein said insulator array provides support and separates said discharge array from said collection capture array only around their peripheral regions.

10. (Currently Amended) An apparatus comprising:

a mask;

exposure radiation incident on said mask; and

an electrostatic pellicle system for attracting contaminants that is

disposed between said mask and said exposure radiation.

11. (Original) The apparatus of claim 10 wherein said electrostatic pellicle system comprises:

a discharge array; and

a collection capture array parallel to said discharge array.

12. (Original) The apparatus of claim 11 wherein said discharge array has been negatively charged.

13. (Original) The apparatus of claim 12 wherein said collection capture array has been positively charged.

14. (Original) The apparatus of claim 13 further comprising a power supply.

15. – 18. (Canceled).